Friday, September 6, 2013 The 9th Japan TRIZ Symposium J17

Technology trends of TRIZ problem solving and analysis

PATBRAIN Co.

Toshimitsu Kataoka



Does TRIZ contribute to the patent acquisition?

"The invention is called remove of technical contradiction. If the objective criterion is used, the objectivization of the patent application clerical work can be remarkably done." Genrich Saulovich Altshuller

G. Altshuller From "Introduction to the invention conception"

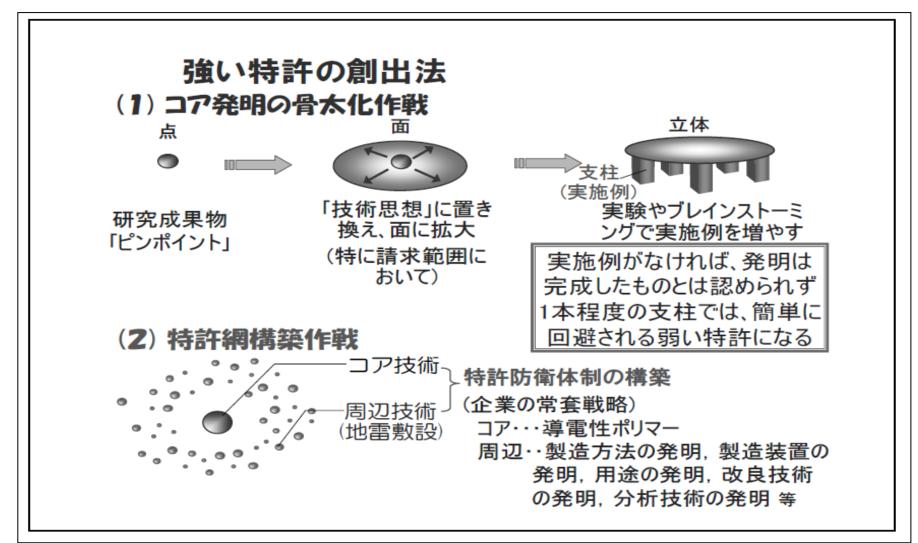


What is the idea to be able to acquire the patent?

The examiner of Patent Office and the person related to Intellectual Property think like this.

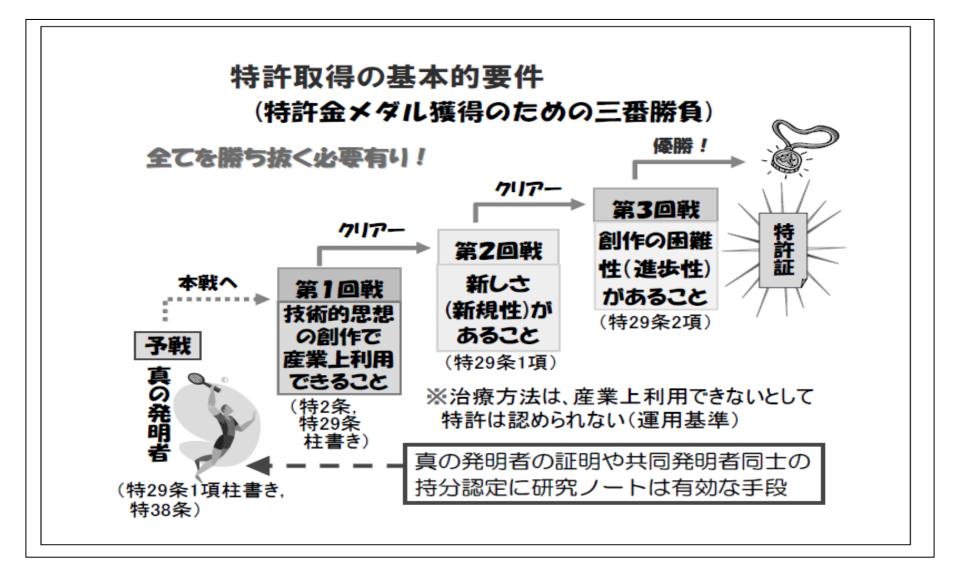


How should I do to take a strong patent?



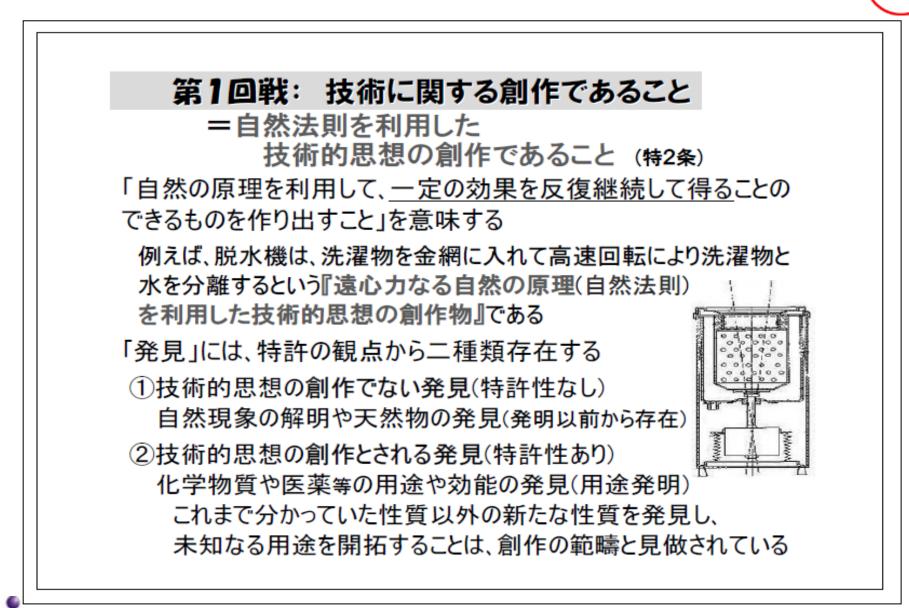


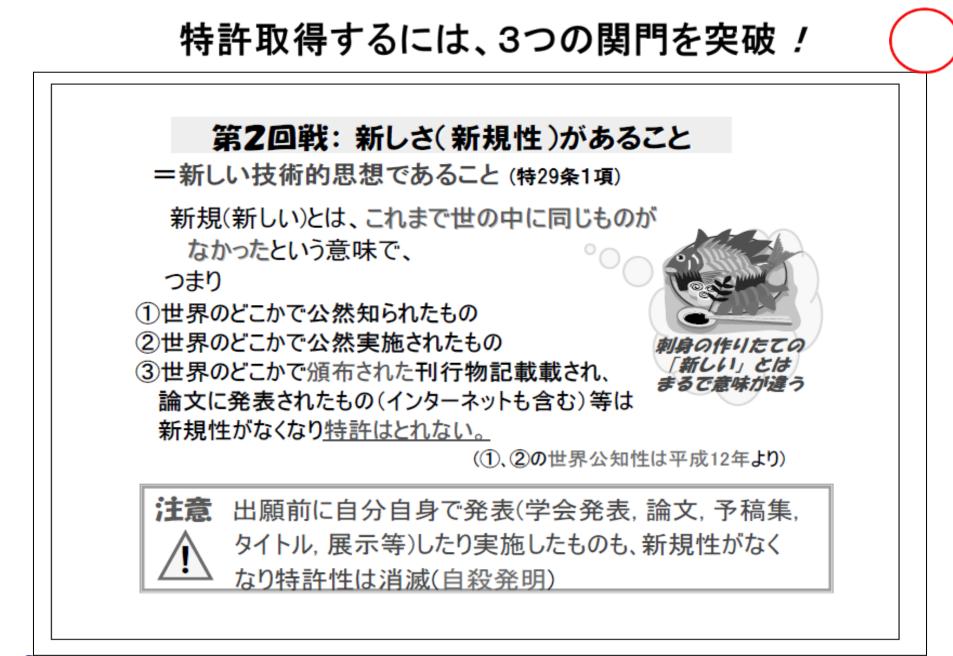
特許取得するには、3つの関門を突破!



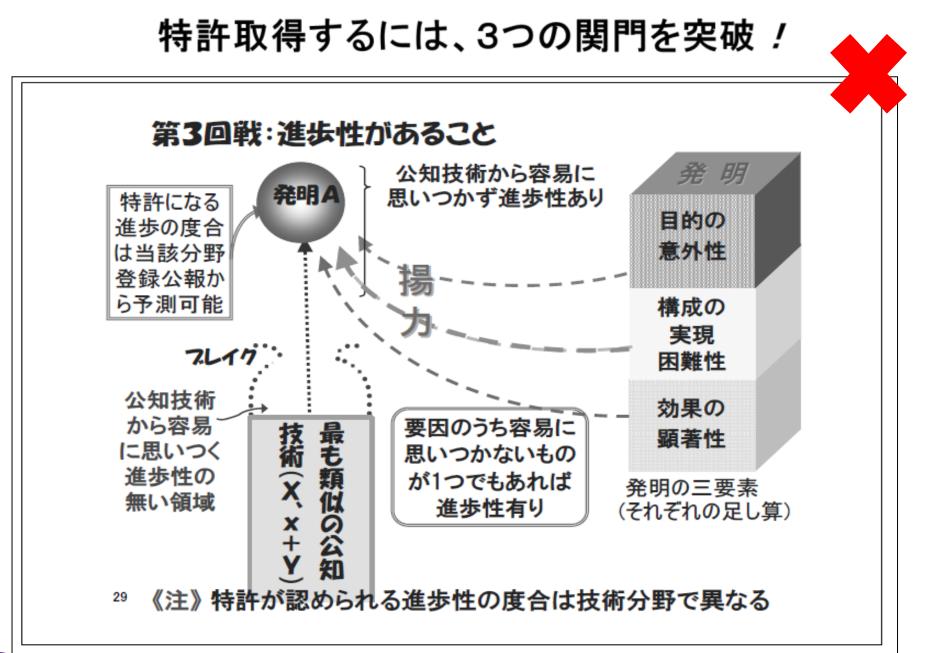


特許取得するには、3つの関門を突破!



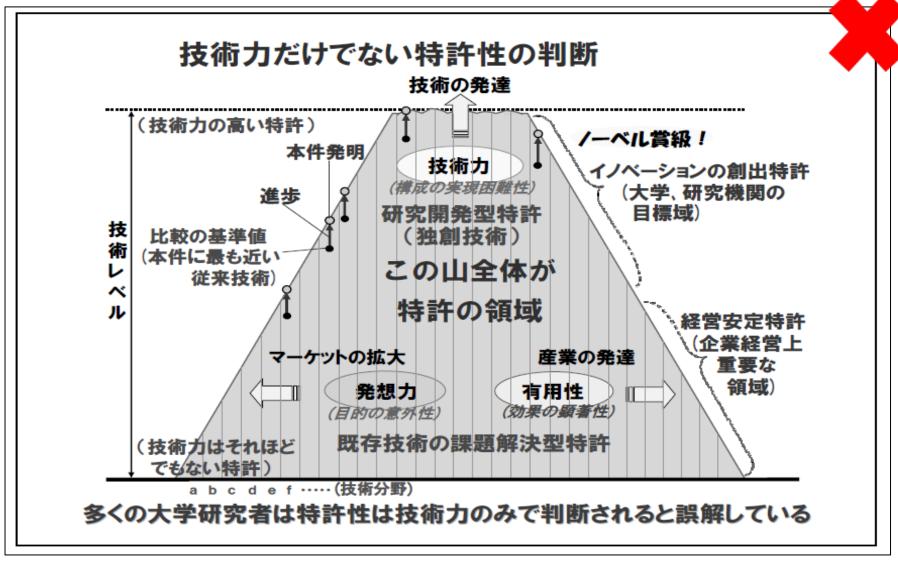






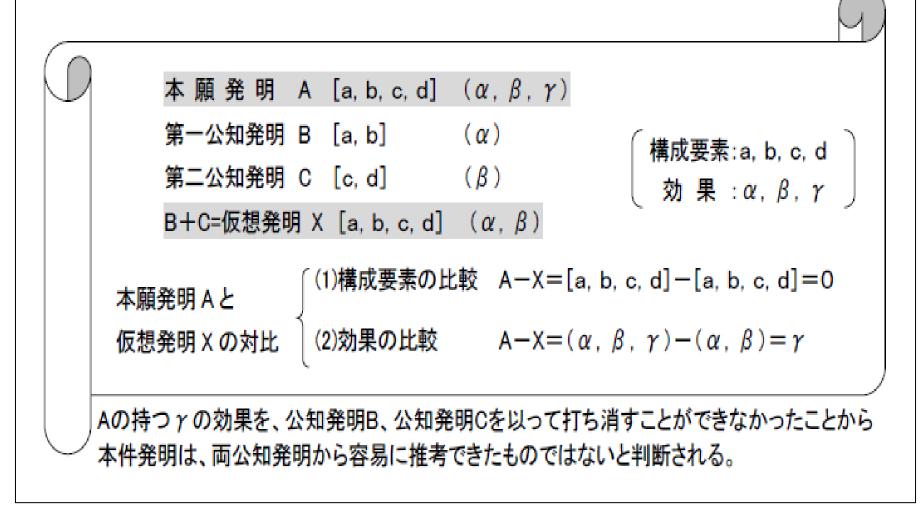
Necessary of technological level

⇒ technology + conception power + utility + difficulty



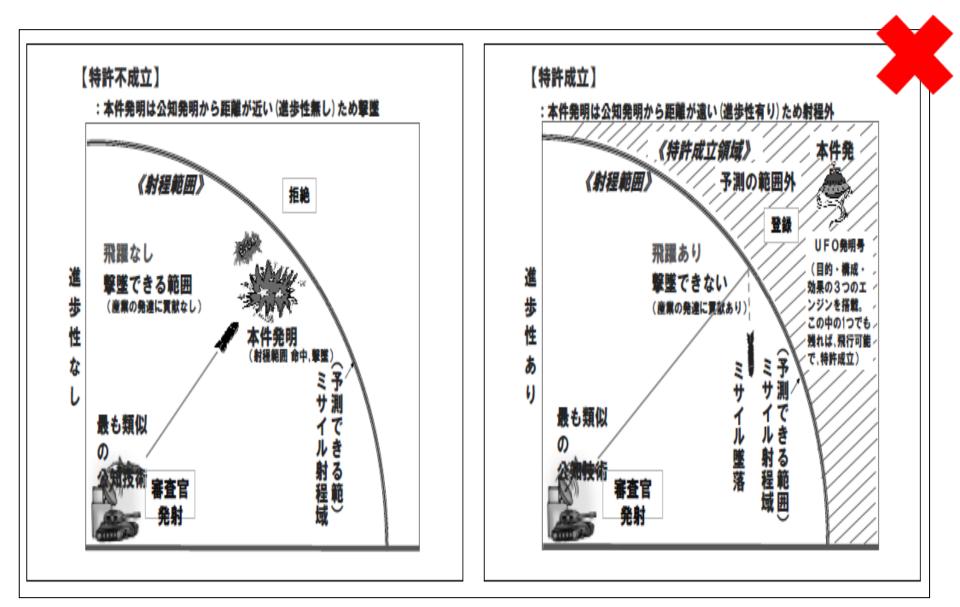


Whether a patent can be acquired or not is a relative comparison with the known art





The examiner decides the prediction horizon of the patent approval and the failure





..".. from the July edition in 2008 [shizai] [purizumu]"

There only has to exist a difficulty not predictable from the known art! 特許性の判断は「ひき算の法則」 い技 析思想(目的 完成させ 最も類似の 効果の、゙ずれかに)(XやX た発明 公知技術 成、 は存在しない) X又はX+ α:ゼロは同一、プラスは改 αによるAの効果 * 意 良、マイナスは後退発明 XやX╁Yから予測できない (注)最も類似の公知技術は ・単独の場合(X)と 創作の困難性 複数を(審査官の裁量で) (進歩性)あり 組合せた(X+Y)とがある。 ...特許取得には最も類似の 公知技術の把握が不てな a th

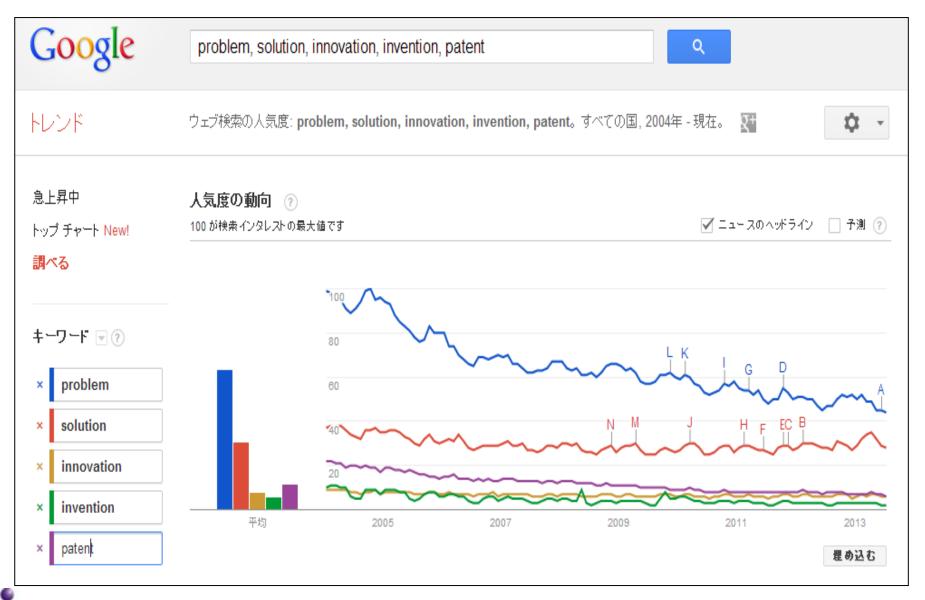
..".. from the July edition in 2008 [shiza

What is the idea to be able to acquire the patent?

Which place popularity do the patent and TRIZ have on the Web site?

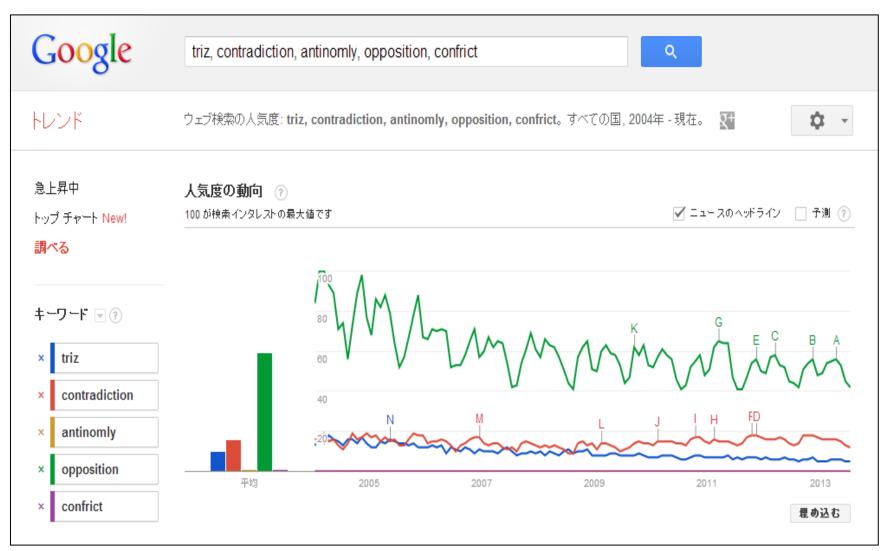


Web retrieval information that relates to TRIZ (1)



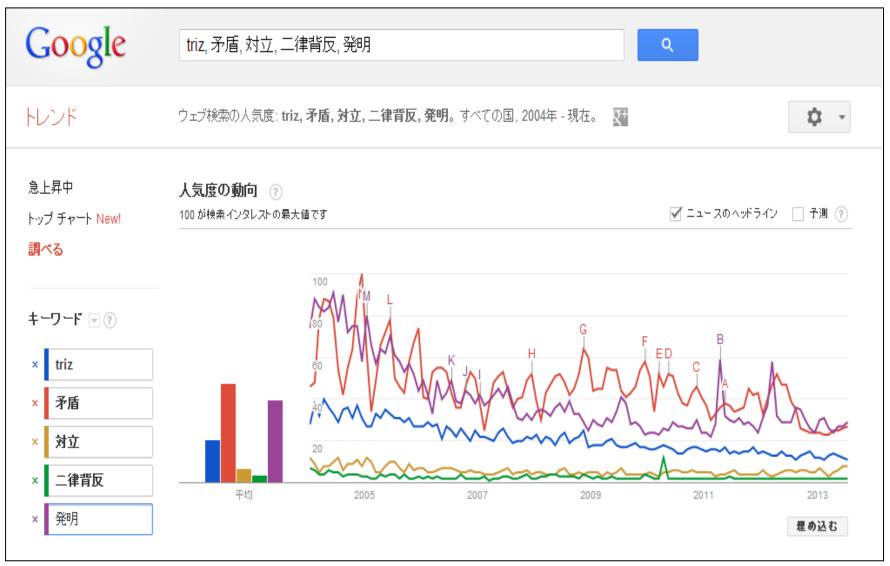
From www.google.trends/explore?

Web retrieval information that relates to TRIZ (2)



From www.google.trends/explore?

Web retrieval information that relates to TRIZ (3)



From www.google.trends/explore?

What is the idea to be able to acquire the patent?

How does the person related to TRIZ think?



Patent analysis report of Darrel Mann & Simon DeWulf

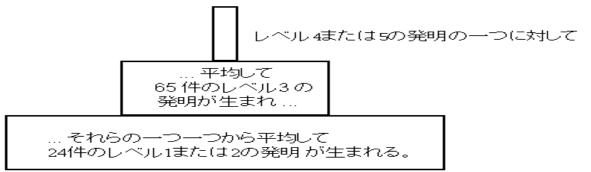
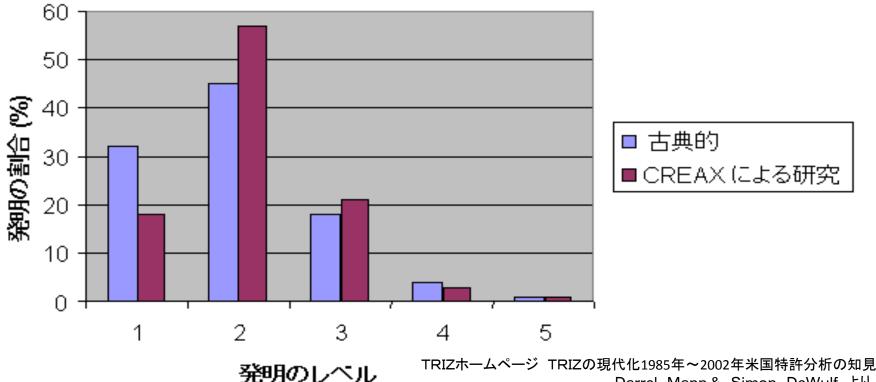


図3. 種々の発明レベル間の特許のクラスタリング



Darrel Mann & Simon DeWulf より

Report of Klaus-Juergen Uhrner (KACO) (1)

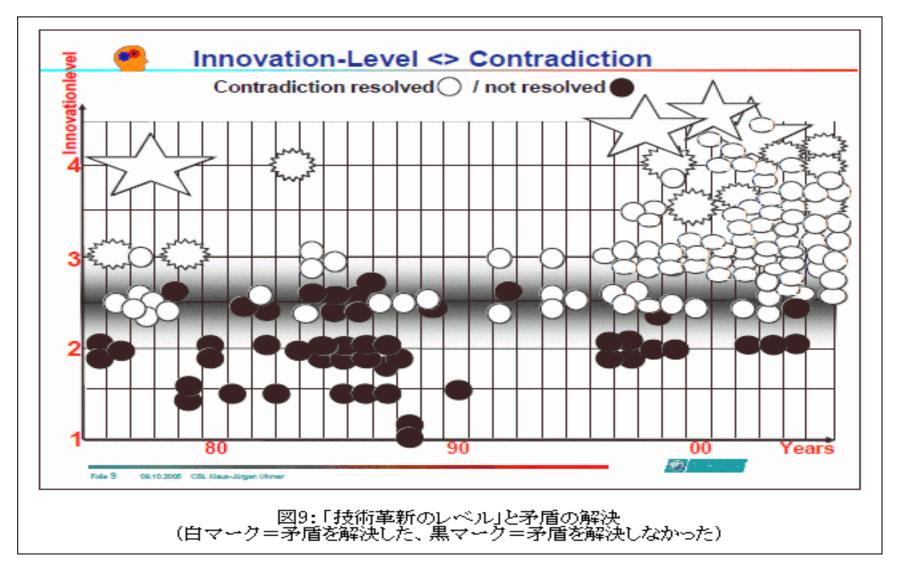
BRAIN

The recurrence to the creation ability - The effect of TRIZ was proven by results -.

Level of technical improvement	Former idea	Contradiction and confrontation	Compromi se	The neighborhood with ultimate ideal solution	Technology	Technical improvement	Knowledge that is necessary	Position in market	Rate of Retune
īv	Change in dramatic form	It specifies, and it solves it by a dramatic, new solution.	It completely cancels it.	It has approached plainly.	The technology is exceeded now.	Hit that exceeds present technology Sour -	A usual paradigm of engineering is exceeded.	To the leader in the market	It is improvement 15% in distinctness.
Ш	It changes plainly.	It specifies, and it solves it by a new element.	It practically cancels it.	Or is similar that approached.	Range of present technology	Range of present technology drinking Break through -	From other study fields	Improvement	Improvement 10%
Π	It changes qualitati vely, and is not basic.	It specifies, and it decreases.	Still still existence	Similar or is away (complex increase).	Range of present technology	Advancement is reformative break through though is plain it – It is not.	In my special area + non- commonplace method	Improvement a little	It is possible to improve it.
I	The state as it is	It specifies, and it decreases.	Still still existence	It is far further.	Range of present technology	There is no reformative solution.	In my special area	There is no improvement.	There is no improvement.

The TRIZ homepage: From the pp. 43-50 report on the 5th Europe TRIZ society sponsoring "TRIZ Future 2005" November 16-18, an international conference, Graz, Austria, and 2005

Report of Klaus-Juergen Uhrner (KACO) (2)



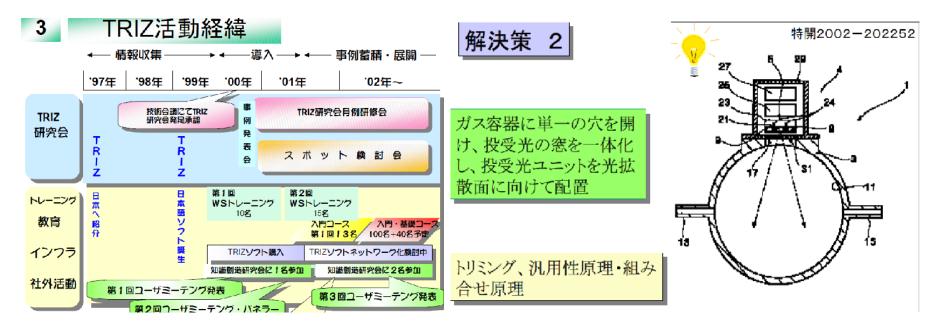


The TRIZ homepage: From the pp. 43-50 report on the 5th Europe TRIZ society sponsoring "TRIZ Future 2005" November 16-18, an international conference, Graz, Austria, and 2005

The invention level recognition of a simple invention is difficult



Patent acquisition only in numeric row and hole. Very, sales of 3.5 trillion yen or more. At first, no one evaluated the application. It was not appreciable.



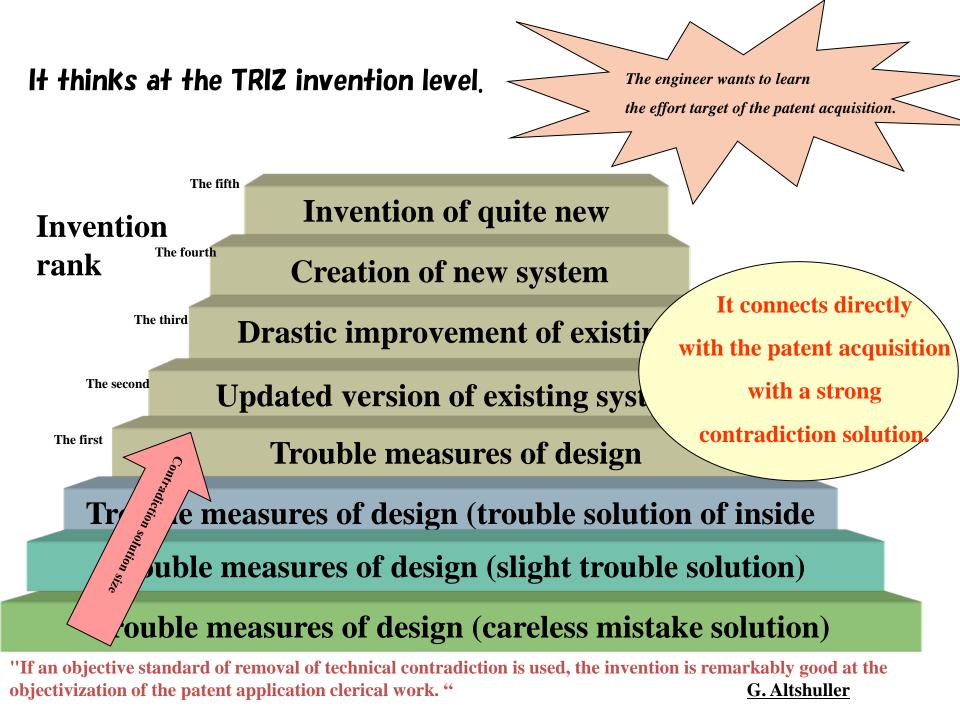
出願評価のための出願検討マップの作成

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	丸みさ神った果方が			ſ
	₹1.—J税税税		•	T
ini.	検測剤を設ける		本人力意の前に設置する	T
	(他先想用)吧)	液晶を用いる	愛羅:「猿島、コレスヤルからせん冒険」で検索する	
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	いないである		教地とする。	
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		空気の有效でブラウン運動を強い取扱させる		t
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		装飾をはな用いて表明させる	容易を2重要進とし内部容易は法などの認能体とする。カヨニ射する法認能体験対子を内容	t
			の容易内能改善に進行に、容易本能上に認定された年夏で決然後は激発手を受動させる事で	
			服 焼きせる。	
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			ガスロドライアイスの気を湯だる 。	t

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創出した解決策の代表例

August 28-30 in 2002 From the 3rd and Japan IM User Group Meeting announcements



Common sense and lack in common sense of prospects for acquisition of right

Possibility of patent acquisition	General person's common sense	It is possible	to put it on the screening criterion of Patent Office. Invention level (relative comparison with prior art)	It is possible to put it on TRIZ. Invention level (absolute comparison)
	Acceptable	Making to right	Problem solving of contradiction and mutually exclusive dichotomy	Level 5
Acceptable		Easiness	Difficulty, clearness, and two bird a Koku three birds Hop step jump	Level 4
				Level 3
		Making to right	The Columbus's egged invention Motive, purpose, and function/one composition	Level 2
	No.	Difficulty	difference	Level 1
		Motive, t	arget problem, function, the same composition or resemblance	Level 1
No.			Mere design change	Level 2
			Level 3	
			Selection of optimum material	Level 4
		Level 5		

As for right or wrong of making to the right, it is controlled whether to show the essence of the invention in the patent specification along an objective standard "Removal of contradiction".

It is said that TRIZ was established statistically analyzing millions of patents. Is this true?

Is TRIZ really useful for the patent acquisition?



Cannot you know the TRIZ activity from patent information? Invention analysis of patent journal

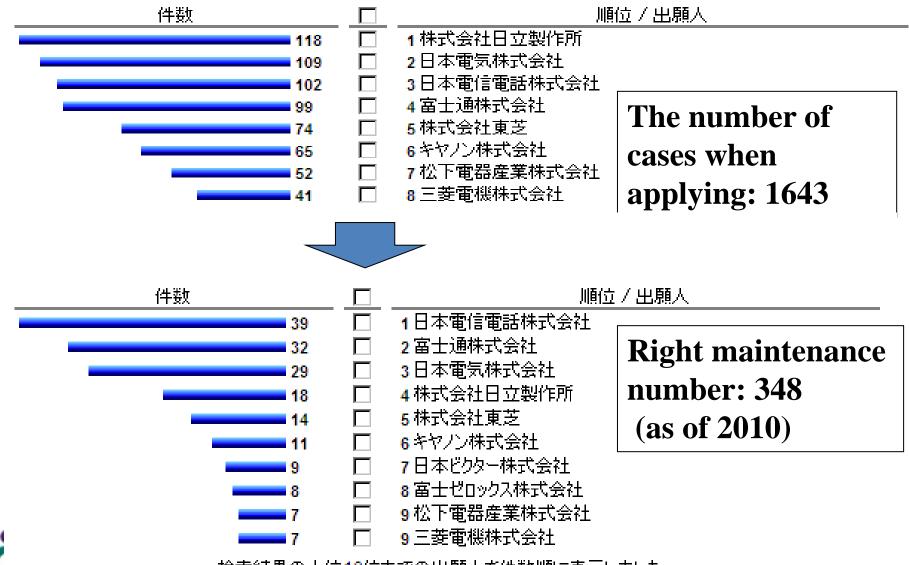
発	明解	↓ 析事例集(Vol.1)	NPO法人			目次 はじめに 発明解析事例インデックス 3 発明解析シートの見方 6 解析メモの見方 6 解析メモの見方 8 発明解析シート、解析メモ ●機械系-一般機械、建築・上木、光学、日用品等 12 ●電気系、情報、制約、回路、温信等 46 ●化学系: 対戦、バイオ、食品、合成等 88 公開特許公報の入手方法 巻末 みとがき
	e 3461	竞明解析	4pan TRIZ Society 事例インデ: 参覧書や 特益する-CBE子 開音者CBE子	ック) us	推荐 新聞(16章	Cogning Council State State Science 2
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					請求の範囲	る、そして、平面状態のシャション材包24-0242と、制作症材1582、素性性シーン状体になる、それらの濃縮を下面にして、体や地面に放置す る、これには、少な少い水材包24-0242、制作症状が34、パーラーンルンドの形成する。 「国家項1]可備性のある50-ド状体(2)と、長平板の形状で数50、パーラーンルンドの形成する。 「国家項1]可備性のある50-ド状体(2)と、長平板の形状で数50、パーラーンルンドの構成する。 たりたいまり、少ない水材包4-0242、第11111111111111111111111111111111111

"Contradiction and mutually exclusive dichotomy" patent application trend analysis in 2010



Retrieval and analysis by WISDOMAIN Co. FOCUST-J

"Contradiction and mutually exclusive dichotomy" patent prosecution history analysis in 2010



検索結果の上位10位までの出願人を件数順に表示しました。

Patent application and registration situation concerning key words "contradiction, mutually exclusive dichotomy, confrontation" as of 2013

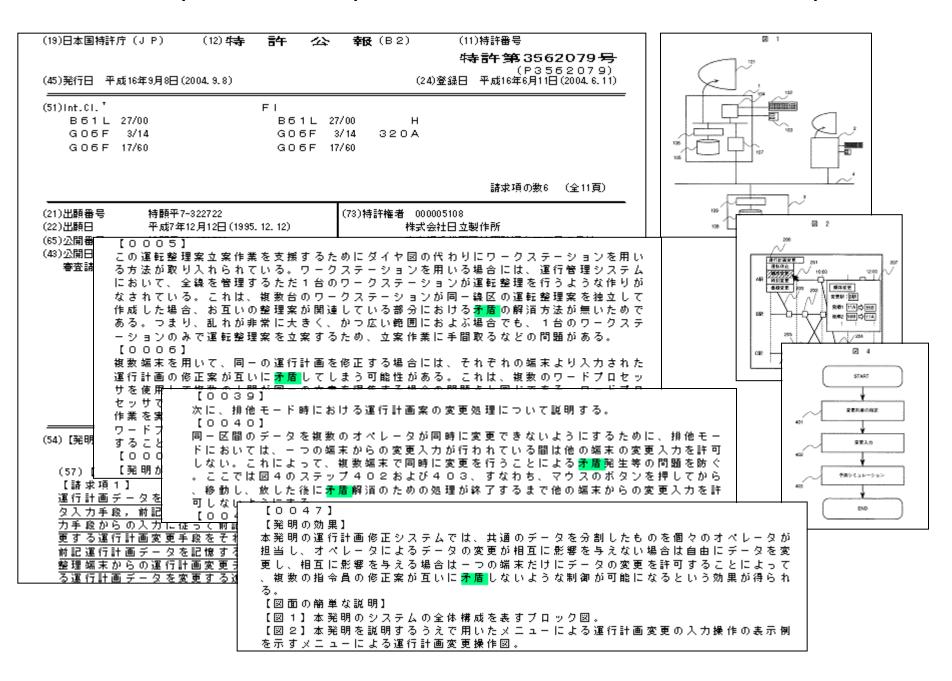
— Search condition –

[retrieval period] January 1, 1985 – June 30, 2013
[official report for retrieval]Patent/official report of practical opening to the public and official report of making public
Official report of re-making public, patent journal, and publication of examined applications
[use data base] JP-NET

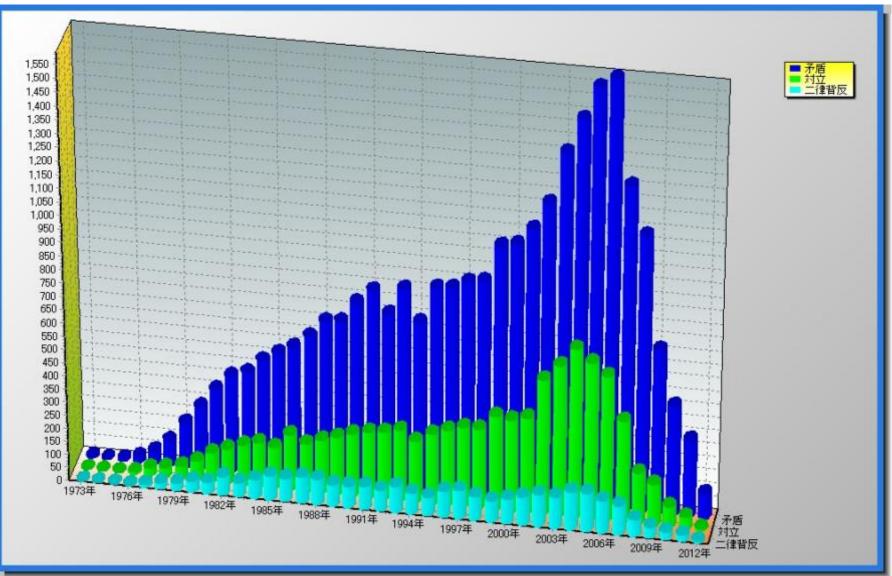
Note : The main enumeration is the one having done to understand a rough tendency, and no one to guarantee reliability and the reproducibility etc. of data.



Patent official report concrete example that described "contradiction" in Detailed Descriptions

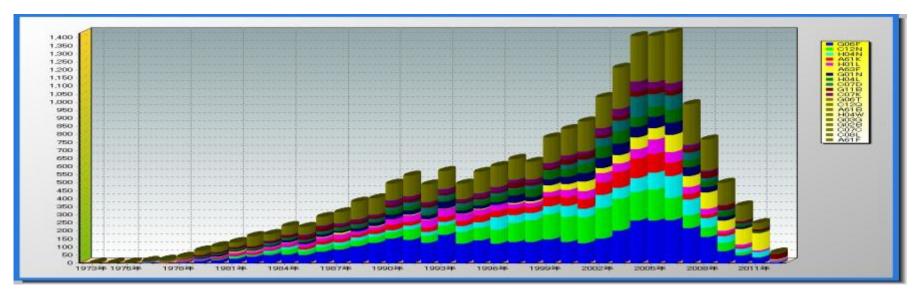


Yearly application status of each key word in the patent journal, etc.





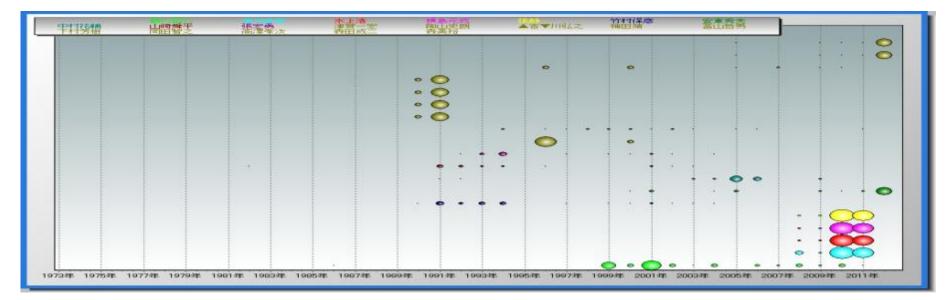
Yearly accumulated IPC application status in the patent journal, etc.



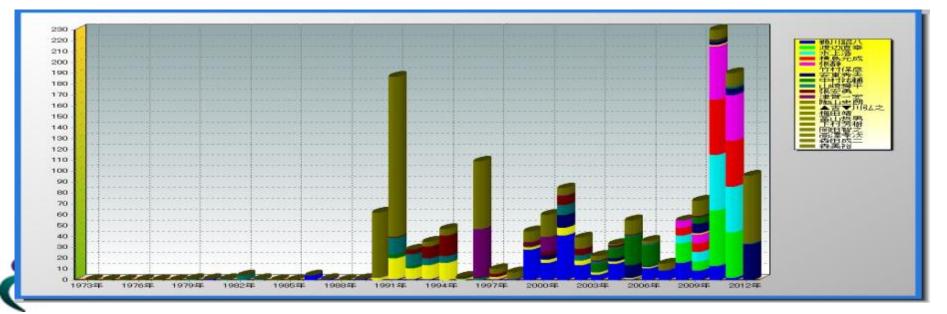
Yearly agent application status in the patent journal, etc.

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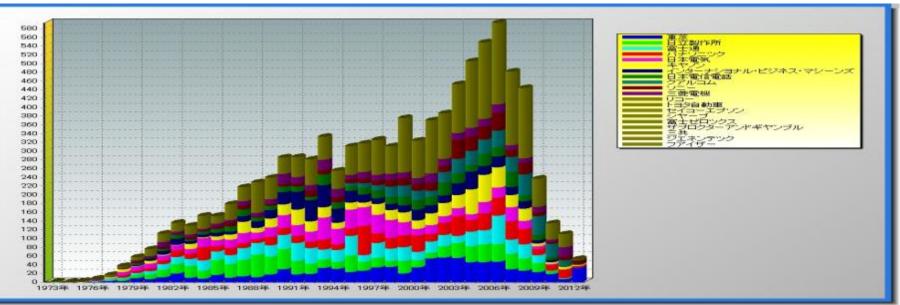
Yearly application status of each inventor in patent journal, etc.



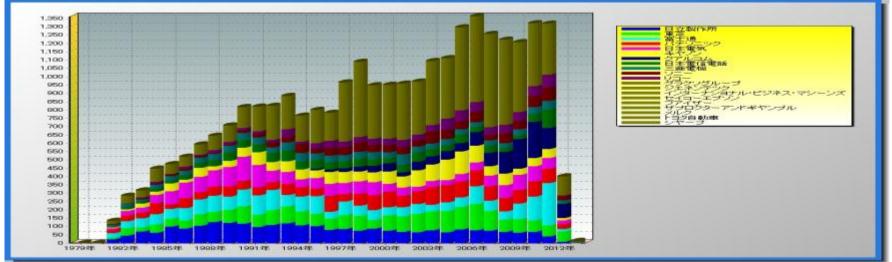
Yearly inventor accumulated application status in the patent journal, etc.



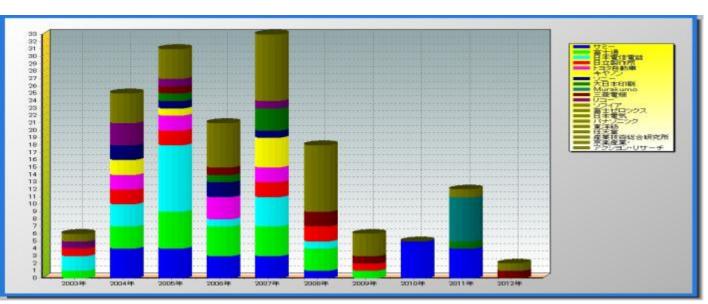
Yearly patent application and registration status as of 2013 (1)



Top 20 companies describing contradiction, mutually exclusive dichotomy, confrontation in the registered official report

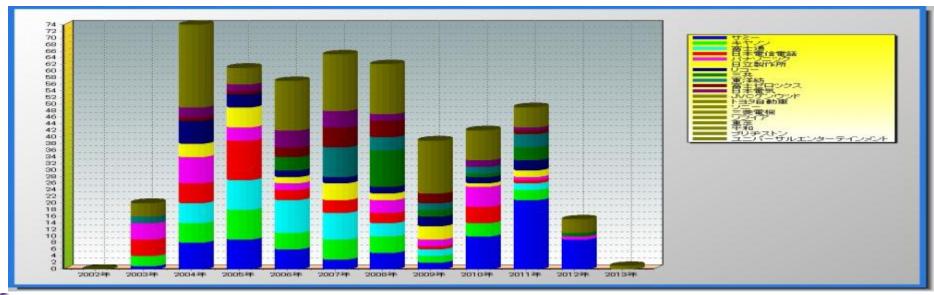


Top 20 companies describing contradiction, mutually exclusive dichotomy, confrontation in the public official report PATBRAIN



Yearly patent application and registration status as of 2013 (2)

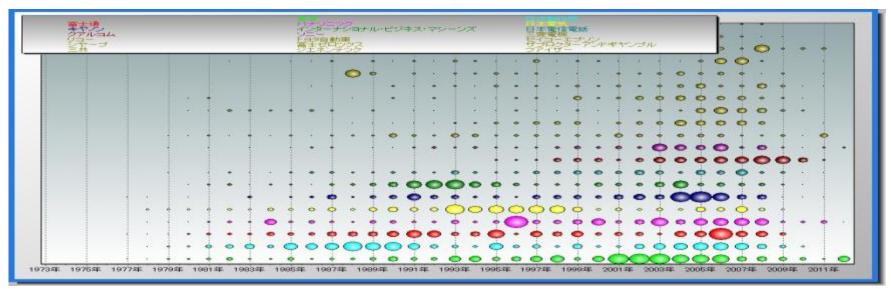
Describing contradiction, mutually exclusive dichotomy, confrontation in the Effect Description field of the registered official report



Describing contradiction, mutually exclusive dichotomy, confrontation in the Effect Description field of the public official report

PATBRAIN

Yearly patent application and registration status as of 2013 (3)



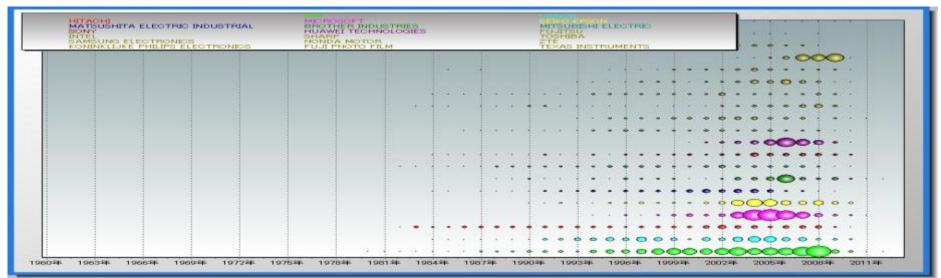
Bubble chart of top 20 companies describing contradiction, mutually exclusive dichotomy, confrontation in the Description field of the registered official report

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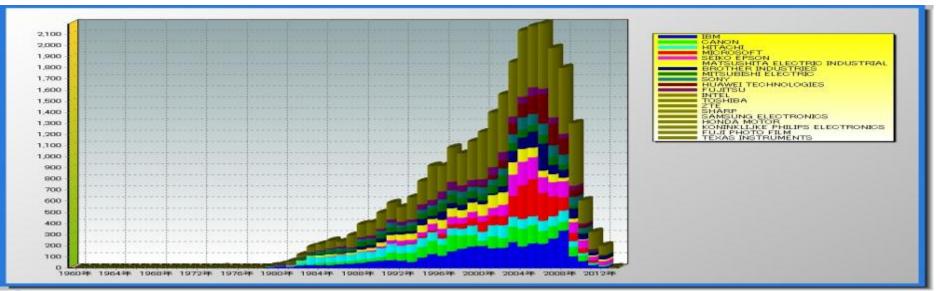
ATBRAIN

Bubble chart of top 20 companies describing contradiction, mutually exclusive dichotomy, confrontation in the description field of the public official report

Yearly patent application and registration status as of 2013 (4)



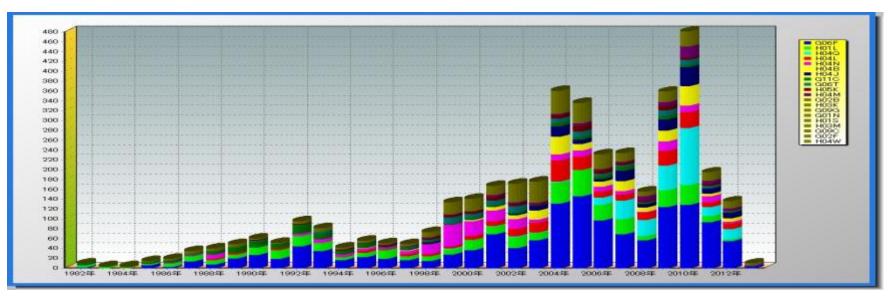
Bubble chart of top 20 companies describing contradiction, mutually exclusive dichotomy, confrontation in the Word Wide registered official report



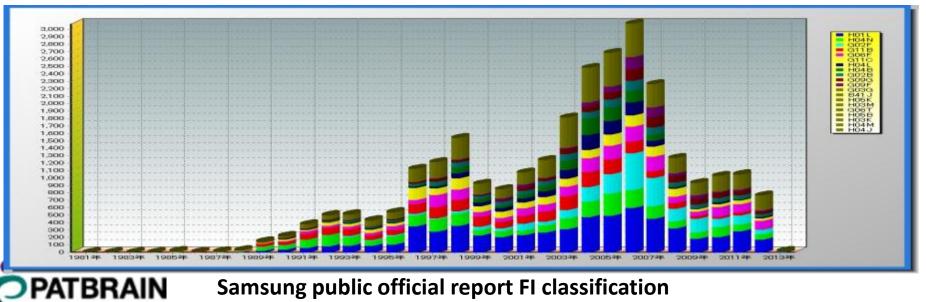
Top 20 companies describing contradiction, mutually exclusive dichotomy, confrontation in the Word Wide registered official report

PATBRAIN

Yearly patent application and registration status as of 2013 (5)

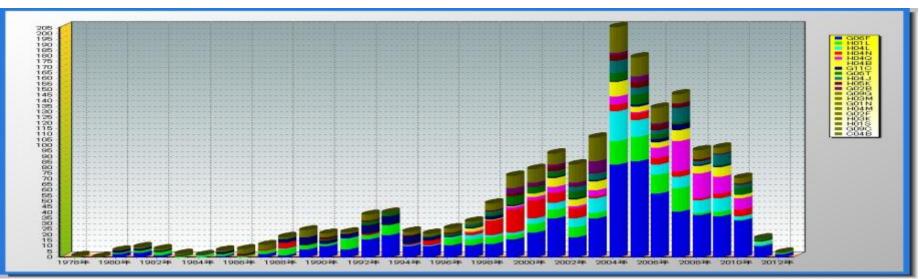


Intel public official report FI classification

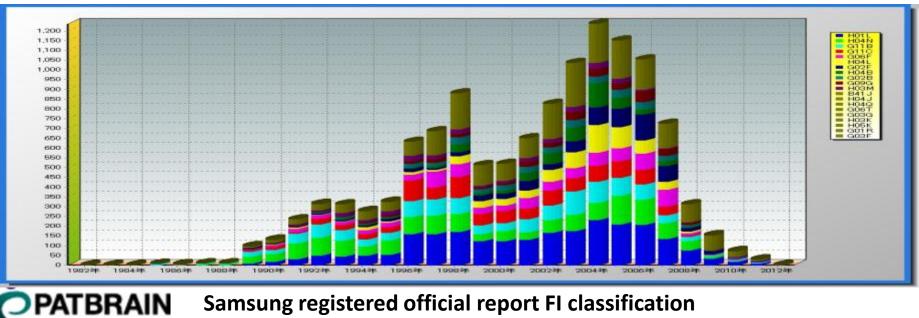


Samsung public official report FI classification

Yearly patent application and registration status as of 2013 (6)



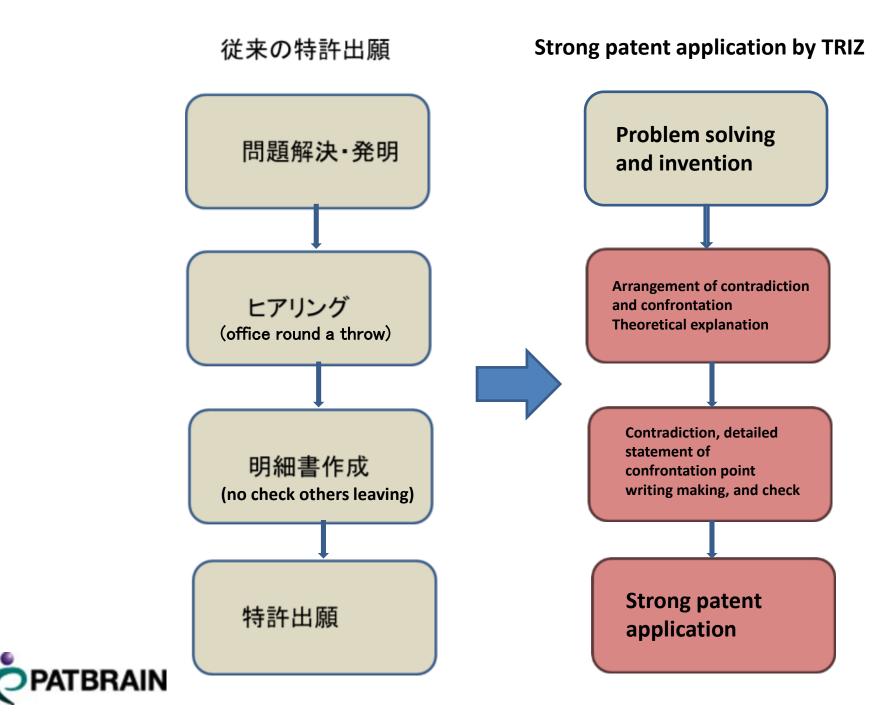
Intel registered official report FI classification



Samsung registered official report FI classification

Consideration

- It is surmisable, and can know TRIZ activity of its company and the other companies handily and promptly because of the patent information analysis that assumes "Contradiction, mutually exclusive dichotomy, and confrontation" to be a key word.
- Making the TRIZ activity visible can be demonstrated in one and a half years if patent applying for the result of the TRIZ activity.
- The TRIZ activity contributes to a patent application number increase and the registration rate improvement.
- There is danger of the knowhow outflow, too, if it is not possible to make it to the right even if applying for the patent. It aims at the registration rate improvement with TRIZ.
- It logically describes by using "Contradiction, mutually exclusive dichotomy, and confrontation" that becomes a reason to prove the difficulty in the patent specification as a key word for strong patent acquisition.



Summary

 The TRIZ activity can be objectively evaluated by patent information.

- "Removal of technical contradiction" is achieved by TRIZ. If it is shown to describe this clearly in the patent specification, and to clear "Objective criterion". 'Kill two birds with one stone"effects of the problem solving and the patent acquisition are demonstrated, and the contribution of the TRIZ activity is plain. - Making good use of TRIZ from the problem solving start, and understanding contradiction, the mutually exclusive dichotomy, and the confrontation lead to strong patent acquisition.

Thank you for your attention

Please send inquiries to this presentation, etc. to the following:

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